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APPLICATION NO.	FILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO.	
10/657,068	09/09/2003	Toshiaki Iwamatsu	241807US-2DIV	9191	
22850	7590 10/22/2004		EXAMINER		
OBLON, SPIVAK, MCCLELLAND, MAIER & NEUSTADT, P.C. 1940 DUKE STREET			HUYNH, ANDY		
	SIREEI UA, VA 22314		ART UNIT PAPER NUMBER		
			2818		
			DATE MAILED: 10/22/2004	ļ	

Please find below and/or attached an Office communication concerning this application or proceeding.

	<u> </u>			(19ru			
		Application No.	Applicant(s)				
Office Action Summary		10/657,068	IWAMATSU ET AL.				
		Examiner	Art Unit				
		Andy Huynh	2818				
Period fe	The MAILING DATE of this communication apport Reply	pears on the cover sheet with	the correspondence address				
THE - Exte - after - If the - If NO - Failt Any	ORTENED STATUTORY PERIOD FOR REPLIMAILING DATE OF THIS COMMUNICATION. nsions of time may be available under the provisions of 37 CFR 1.1 SIX (6) MONTHS from the mailing date of this communication. e period for reply specified above is less than thirty (30) days, a replication of the provision o	36(a). In no event, however, may a rep y within the statutory minimum of thirty will apply and will expire SIX (6) MONTI o, cause the application to become ABA	ly be timely filed 30) days will be considered timely. HS from the mailing date of this communicati NDONED (35 U.S.C. § 133).	on.			
Status							
1)⊠	Responsive to communication(s) filed on 30 S	eptember 2004.					
2a)□		s action is non-final.					
3)	Since this application is in condition for allowance except for formal matters, prosecution as to the merits is						
	closed in accordance with the practice under Ex parte Quayle, 1935 C.D. 11, 453 O.G. 213.						
Disposit	ion of Claims						
4)⊠	☑ Claim(s) <u>11-27</u> is/are pending in the application.						
	4a) Of the above claim(s) <u>13-27</u> is/are withdrawn from consideration.						
5)□	Claim(s) is/are allowed.						
6)⊠	Claim(s) <u>11 and 12</u> is/are rejected.						
7)	Claim(s) is/are objected to.						
8)□	Claim(s) are subject to restriction and/or election requirement.						
Applicat	ion Papers	•		•			
9)□	The specification is objected to by the Examine	er.					
10)🛛	10)⊠ The drawing(s) filed on <u>09 September 2003</u> is/are: a)⊠ accepted or b)□ objected to by the Examiner.						
	Applicant may not request that any objection to the drawing(s) be held in abeyance. See 37 CFR 1.85(a). Replacement drawing sheet(s) including the correction is required if the drawing(s) is objected to. See 37 CFR 1.121(d).						
11)	The oath or declaration is objected to by the Ex			(u).			
Priority	under 35 U.S.C. § 119						
	Acknowledgment is made of a claim for foreign ☐ All b)☐ Some * c)☐ None of: 1.☐ Certified copies of the priority document		19(a)-(d) or (f).				
	2. Certified copies of the priority document		plication No. <u>09/985,020</u> .				
	3. Copies of the certified copies of the prior	rity documents have been r	eceived in this National Stage				
	application from the International Burea	u (PCT Rule 17.2(a)).					
* (See the attached detailed Office action for a list	of the certified copies not re	eceived.				
•							
Attachmer	ut(s) ce of References Cited (PTO-892)	4) 🗍 Interview Su	mmary (PTO-413)				
	ce of References Cited (P10-692) ce of Draftsperson's Patent Drawing Review (PT0-948)	Paper No(s)	Mail Date				
	mation Disclosure Statement(s) (PTO-1449 or PTO/SB/08) er No(s)/Mail Date <u>9903,123003,22404</u> .	5) Notice of Inf 6) Other:	ormal Patent Application (PTO-152) 				

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DETAILED ACTION

Election/Restrictions

In the Response to the Election of Species Requirement dated 09/30/2004,
Applicants have elected with traverse Species A (claims 11-12 and 22-25) is
acknowledged. However, Applicants believe that claims 22-25 are not readable on
Species A. Examiner respectfully agrees with Applicants that the semiconductor of
claims 11-12 is shown in Figure 32, and the semiconductor of claims 22-25 is shown in
Figure 52. Figures 32 and 52 are two different embodiments. Thus, an election of claims
11-12 and 22-25 is further required. Applicants further elect claims 11-12 for
examination on the merits is acknowledged. Accordingly, claims 13-27 are withdrawn
from consideration as being directed to a non-elected invention. See 37 CFR 35 §
1.142(b) and MPEP § 821.03. Applicants have the right to file a divisional application
covering the subject matter of the non-elected claims 13-27.

Priority

Acknowledgment is made of applicants' claim for foreign priority under 35 U.S.C. 119(a)-(d). The certified copy has been filed in Parent Application No. 09/985,020, filed November 01, 2001.

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Information Disclosure Statement

This office acknowledges receipt of the following items from the applicant: Information Disclosure Statement (IDS) filed on 09/09/2003, 12/30/2003 and 02/24/2004. The references cited on the PTOL 1449 form have been considered.

Claim Rejections - 35 USC § 103

The following is a quotation of 35 U.S.C. 103(a) which forms the basis for all obviousness rejections set forth in this Office action:

(a) A patent may not be obtained though the invention is not identically disclosed or described as set forth in section 102 of this title, if the differences between the subject matter sought to be patented and the prior art are such that the subject matter as a whole would have been obvious at the time the invention was made to a person having ordinary skill in the art to which said subject matter pertains. Patentability shall not be negatived by the manner in which the invention was made.

Claim 11 is rejected under 35 U.S.C. 103(a) as being unpatentable over Verrett (USP: 5,612,243) in view of Korean Patent Application Laid-Open No. 1996-0002744 (English Extract), Applicant's submitted prior art (ASPA).

Verrett discloses in Fig. 1 and the corresponding texts as set forth in column 3, lines 14-30, a semiconductor device comprises:

a semiconductor layer containing a P-well (14) and a N-well (12);

a plurality of semiconductor elements (8, 9, 24 and 25) formed on said semiconductor layer;

an isolation film (16a, 16b and 16c) provided in a surface of said semiconductor layer, said semiconductor elements being electrically isolated from each other by said isolation film; and

a PN junction portion formed by two semiconductor regions of different conductivity types (P-Si and N-Si) in said semiconductor layer provided under said isolation film.

Verrett fails to teach the isolation film including a nitride film provided in a position corresponding to a top of said PN junction portion and having a substantially uniform thickness across said two semiconductor regions; and an upper oxide film and a lower oxide film which are provided in upper and lower portions of said nitride film.

Korean Patent Application No. 1996-0002744 teaches that an element isolation film of a semiconductor element in which a trench is formed on a silicon substrate in order to increase the size of a cell region by minimizing an element isolation region and the reliability of an element can be improved by forming within the trench an element isolation film of laminated structure with good isolation property of oxide film-nitride film-oxide film.

It would have been obvious to one of ordinary skill in the art at the time of the invention was made to form an element isolation film of laminated structure with good isolation property of oxide film-nitride film-oxide film, as taught by Korean Patent Application No. 1996-0002744 to incorporate into Verrett's structure to modify and to form the isolation film of Verrett's structure with an element isolation film of laminated structure with good isolation property of oxide film-nitride film-oxide film in order to improve the reliability of an device.

Claim 12 is rejected under 35 U.S.C. 103(a) as being unpatentable over Verrett (USP: 5,612,243) in view of Korean Patent Application Laid-Open No. 1996-0002744

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(English Extract), Applicant's submitted prior art (ASPA), further in view of Fig. 65 of Applicants' admitted prior art (AAPA).

Verrett and Korean Patent Application No. 1996-0002744 disclose the claimed limitations except for the semiconductor device wherein said semiconductor device is an SOI semiconductor device formed on an SOI substrate including a silicon substrate, a buried oxide film provided on said silicon substrate and an SOI layer provided on said buried oxide film, said semiconductor layer being said SOI layer. However, Fig. 65 of AAPA teaches that the semiconductor device is an SOI semiconductor device formed on an SOI substrate (10) including a silicon substrate (1), a buried oxide film (2) provided on said silicon substrate and an SOI layer (3) provided on said buried oxide film, said semiconductor layer being said SOI layer. It would have been obvious to one of ordinary skill in the art at the time of the invention was made to incorporate an SOI substrate into Verrett's structure to form the claimed invention in order to reduce parasitic capacitance and power consumption, and an operation can be performed at a high speed (see

Conclusion

A shortened statutory period for response to this action is set to expire 3 (three) months and 0 (zero) day from the day of this letter. Failure to respond within the period for response will cause the application to become abandoned (see M.P.E.P 710.02(b)).

Any inquiry concerning this communication or earlier communications from the examiner should be directed to Andy Huynh, (571) 272-1781. The examiner can normally be reached on Monday-Friday from 8:30.AM to 5:00 PM.

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If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, David Nelms can be reached on (571) 272-1787. The Fax number for the organization where this application or proceeding is assigned is (703) 872-9306.

Any inquiry of a general nature or relating to the -status of this application or proceeding should be directed to the receptionist whose phone number is (703) 308-0956.

Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published applications may be obtained from either Private PAIR or Public PAIR. Status information for unpublished applications is available through Private PAIR only. For more information about the PAIR system, see http://pair-direct.uspto.gov. Should you have questions on access to the Private PAIR system, contact the Electronic Business Center (EBC) at 866-217-9197 (toll-free).

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10/16/04

Andy Huynh

andy Muy 2

Patent Examiner